	Hits	Search Text	DB	Time stamp
umber				
	1126	(optical adj waveguide).ti.	USPAT;	2002/11/06
			US-PGPUB	10:54
	36	(optical adj waveguide).ti.and facet and	USPAT;	2002/11/06
		etch\$3	US-PGPUB	10:55
	184	method adj2 forming near2 (optical adj	USPAT;	2002/11/06
!		(component or waveguide))	US-PGPUB	10:55
	62	(channel adj waveguide) and etch\$3 and	USPAT;	2002/11/01
		mask\$3 and light adj transmit\$3	US-PGPUB	08:26
	329	(channel adj waveguide) and etch\$3 and	USPAT;	2002/11/06
į	J., .	mask\$3	US-PGPUB	10:55
	922	channel adj waveguide	USPAT;	2002/11/06
	9	channel adj wavegulde	US-PGPUB	10:57
	1.5	(d d d d a \ a m d a m d		2002/11/01
	15	(ridged adj waveguide)and etch\$3 and	USPAT;	i
	40.40	mask\$3	US-PGPUB	09:21
	4342	waveguide and etch\$3 and mask\$3	USPAT;	2002/11/01
			US-PGPUB	09:23
	206	waveguide and etch\$3 and mask\$3 and	USPAT;	2002/11/06
		dicing	US-PGPUB	10:57
	18	SF6 and O2 and CHF3 and etching	USPAT;	2002/11/06
			US-PGPUB	11:48
	44	(channel adj waveguide)and etch\$3 and	USPAT;	2002/11/01
		mask\$3 and chamber	US-PGPUB	09:50
	312	waveguide and etch\$3 and mask\$3 and	USPAT;	2002/11/01
i		dic\$3	US-PGPUB	10:08
1	ი5	(channel adj waveguide) and etch\$3 and	USPAT;	2002/11/06
;		mask\$3 and facet	US-PGPUB	10:58
	49	waveguide and etch\$3 and mask\$3 and facet	USPAT;	2002/11/04
i		and separat\$3 and dic\$3	US-PGPUB	13:00
_	758	waveguide and etch\$3 and mask\$3 and facet	USPAT;	2002/11/06
	, 5 5	maroguzuo unu soni, o unu marin, i anni anni	US-PGPUB	10:57
	48	waveguide same etch\$3 same mask\$3 same	USPAT;	2002/11/04
	30	facet	US-PGPUB	13:01
	25		USPAT;	2002/11/05
		"NF3.sub." or (flourine near3 gas) or	US-PGPUB	10:56
		oxygen or "CHF3.sub." or HBr)	05 10100	10.00
_	35	etch\$3 adj glass same ("SF.sub.6" or	USPAT;	2002/11/05
	35	"NF.sub.3" or (flourine near5 gas) or	US-PGPUB	11:04
			US PGFUD	11.04
	. ">	oxygen or "CHF.sub.3" or HBr) etch\$3 adj glass same ("SiF.sub.6" or	HSDAT.	2002/11/05
	13		USPAT;	
	2752	"SiF. sub.4" or mTorr)	US-PGPUB	11:11
	3752	etch\$3 same ("SiF.sub.6" or "SiF.sub.4"	USPAT;	2002/11/06
	_	or mTorr)	US-PGPUB	10:58
1	3	, , , , , , , , , , , , , , , , , , , ,	USPAT;	2002/11/05
		and mTorr)	US-PGPUB	11:12
	1.4	etch\$3 same ("SiF.sub.6" same	USPAT;	2002/11/05
		"SiF.sub.4")	US-PGPUB	12:18
	30	etch\$3 same inductive same plasma same	USPAT;	2002/11/05
		("noble gas" or argon or neon or helium)	US-PGPUB	11:18
ļ	95	etch\$3 same (HBr and "SiF.sub.4" and	USPAT;	2002/11/05
		"CHF.sub.3")	US-PGPUB	12:20
	157	etch\$3 same ("SiF.sub.6" or "SiF.sub.4"	USPAT;	2002/11/06
į		same HBr same "NF.sub.3" same "SF.sub.6")	US-PGPUB	08:26
	57	etch\$3 same (("SiF.sub.6" or "SiF.sub.4")	USPAT;	2002/11/06
1	.	same HBr same "NF.sub.3" same "SF.sub.6")	US-PGPUB	10:59
	6	(("5874362") or ("4776661") or	USPAT;	2002/11/06
	9	("5853960") or ("6235214") or ("4652290")	US-PGPUB	10:16
		or ("5710847")).PN.		
İ	95	method adj2 forming near2 (optical adj	JPO;	2002/11/06
ļ	20	(component or waveguide)	DERWENT	10:55
į	r	(component of waveguide)) (channel adj waveguide)and etch\$3 and	JPO;	2002/11/06
	5			
i	re.	mask\$3	DEPWENT	10:55
Ì	3	, , ,	JPO;	2002/11/06
1		etch\$3	DEPWENT	10:55
	3	waveguide and etch\$3 and mask\$3 and	JPO;	2002/11/06
		dicing	DEPWENT	10:57
	3	waveguide and etch\$3 and mask\$3 and facet	JPO;	0002/11/06
			DEP.WENT	10:57
	433	channel adj waveguide	JPO;	2002/11/06
			DERWENT	10:57
		i	ı	

Ī-	174 etchys same ("SiF.sub.6" or "SiF.sub.4"	JPO;	2002/11/06	i
	or mTorr)	DERWENT	10:58	
_	43 C4H8 or "C.sub.4H.sub.8" and etch\$3	USPAT;	2002/11/06	
1		US-PGPUB	11:51	
-	35 C4H8 or "C.sub.4H.sub.8" same etch\$3	USPAT;	2002/11/06	
İ		US-PGPUB	11:51	
1		L	100	